

# Systems Engineering and Modeling at Start-Up Company

by *Gerrit Muller* University of South-Eastern Norway-NISE

e-mail: `gaudisite@gmail.com`

`www.gaudisite.nl`

## Abstract

We have been assisting in applying Systems Engineering techniques and methods in a small (tens of persons) start-up company in the semiconductor process and equipment market. We report our observations in this start-up company with an innovative product operating in a dynamic environment. Start-up companies in general explore new applications or new technologies: an environment full of unknowns, uncertainties and other surprises. In the specific case of semiconductor process and equipment the system is highly multi-disciplinary, amongst others: high precision mechanical, control, optics, chemical, signal processing, and power electronics.

### Distribution

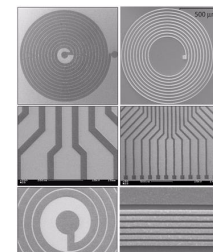
This article or presentation is written as part of the Gaudí project. The Gaudí project philosophy is to improve by obtaining frequent feedback. Frequent feedback is pursued by an open creation process. This document is published as intermediate or nearly mature version to get feedback. Further distribution is allowed as long as the document remains complete and unchanged.

April 3, 2023

status: preliminary

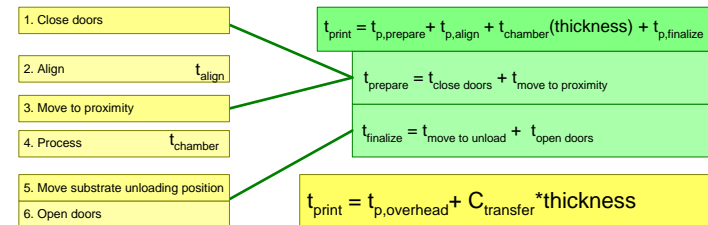
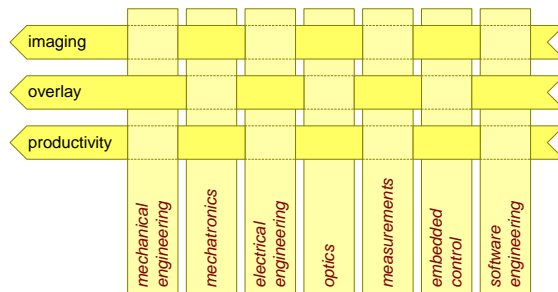
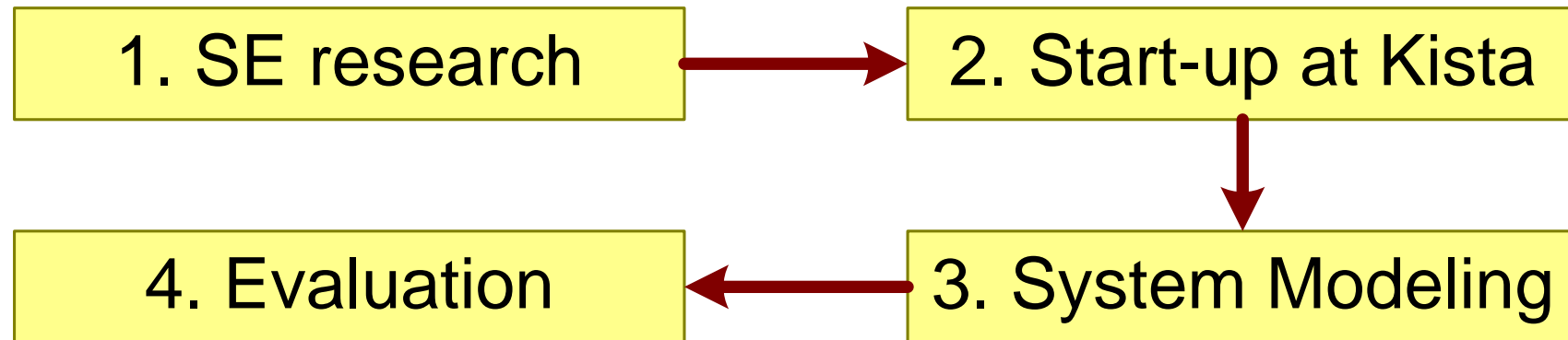
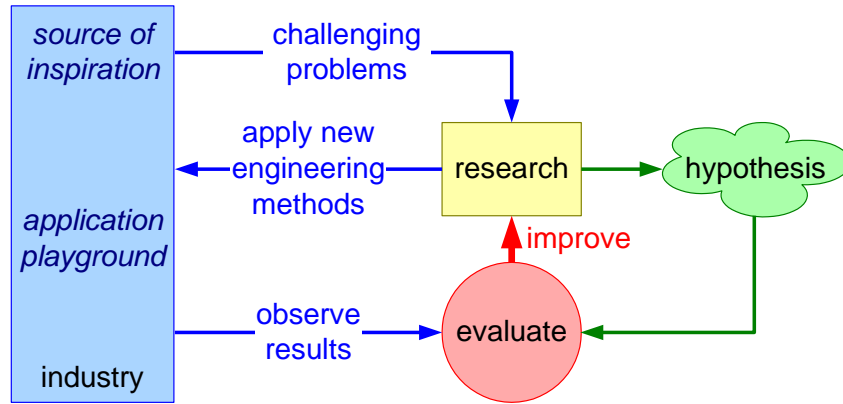
draft

version: 0



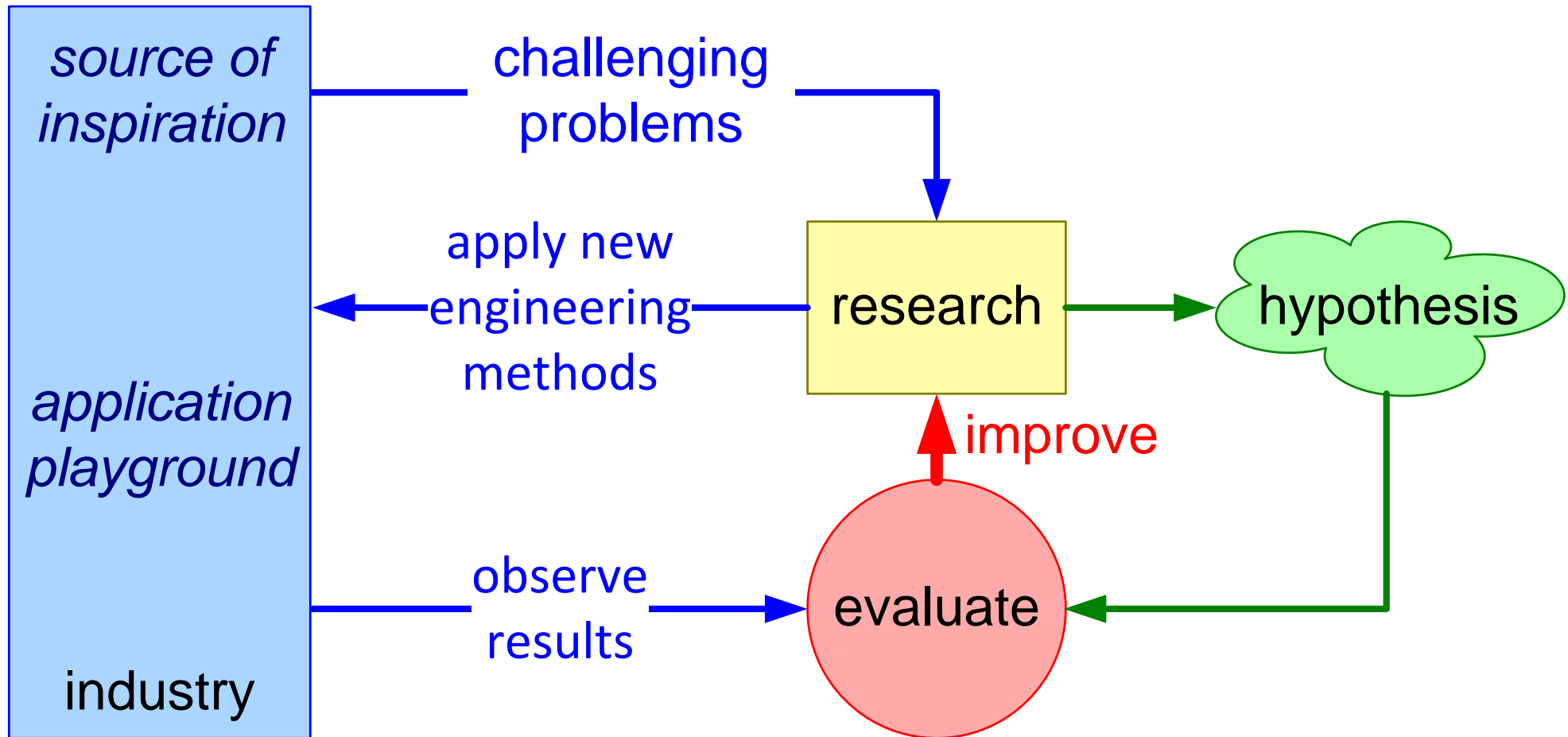
courtesy Replisaurus  
[www.replisaurus.com](http://www.replisaurus.com)

# Figure Of Contents™



*note: original diagram was annotated with actual performance figures for confidentiality reasons these numbers have been removed*

# Industry as Laboratory



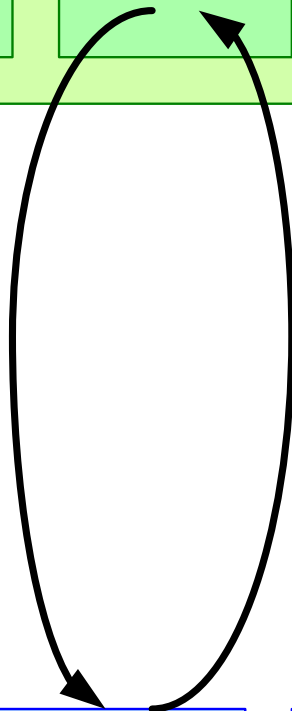
# Industry as Laboratory (2)

intended dissemination and research partners



generalization and consolidation to facilitate use in other domains

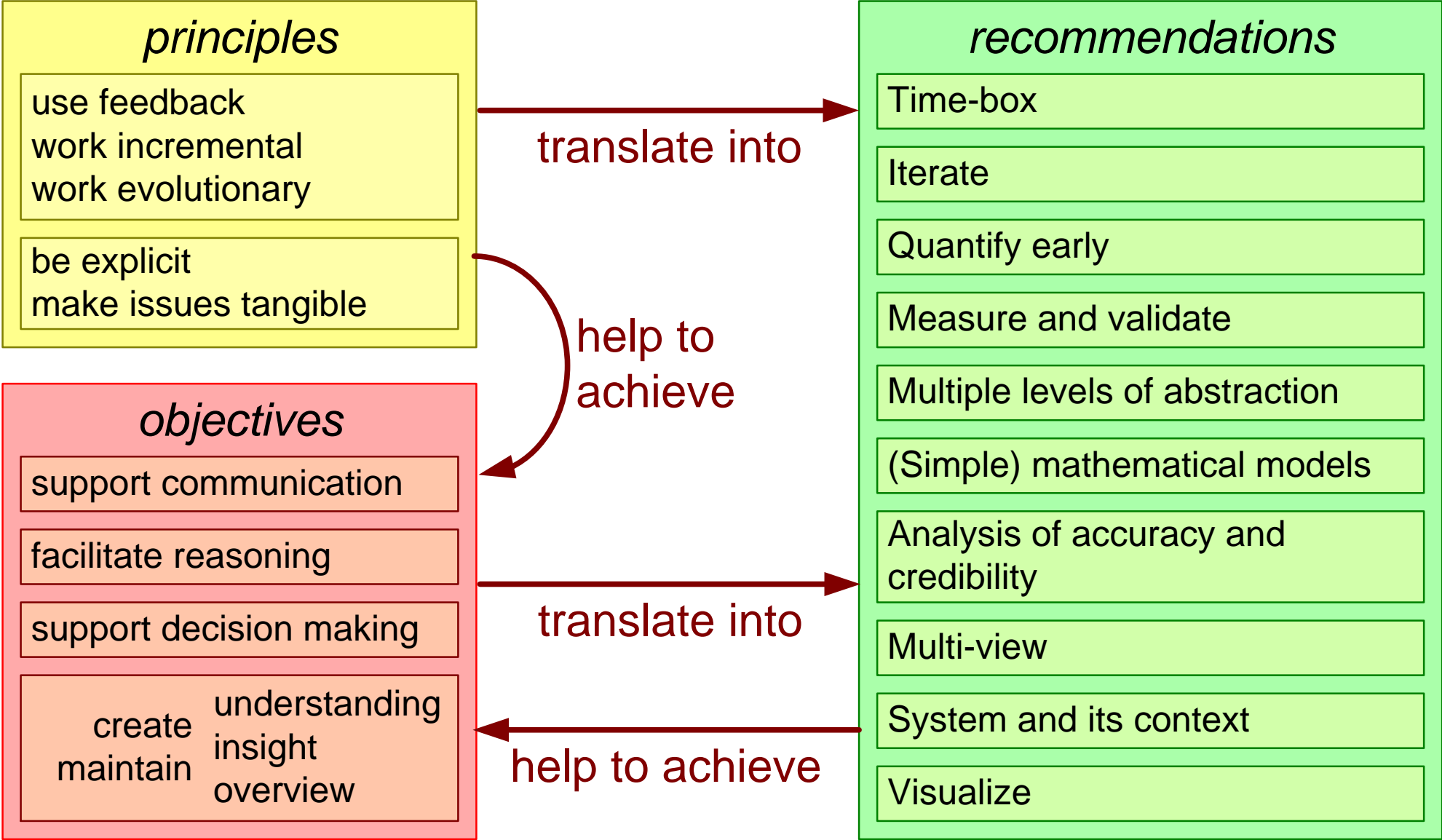
single domain research focus on industrial problem



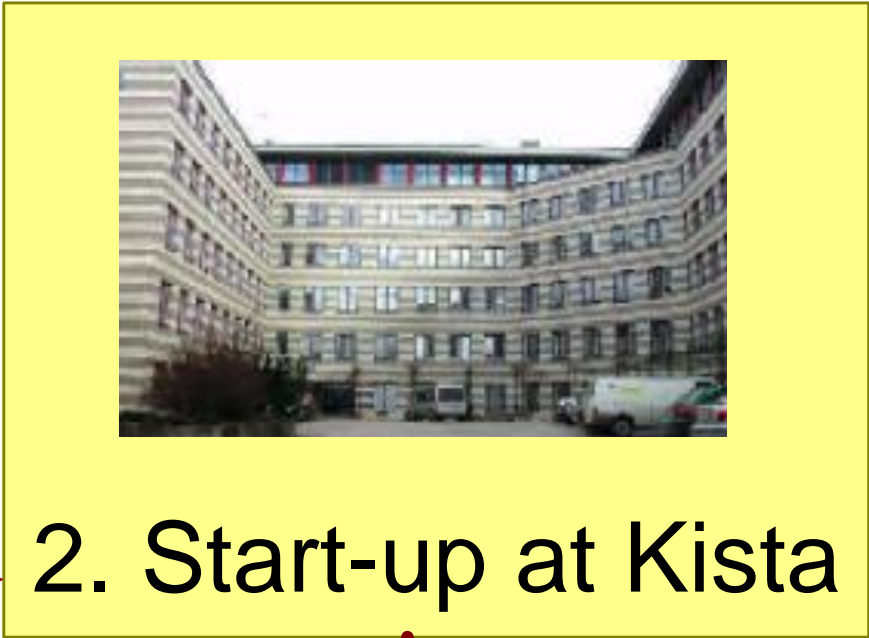
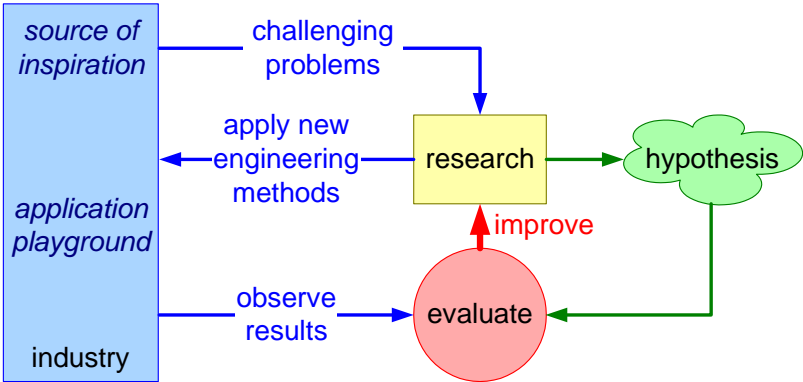
multi-domain research and expertise



# Modeling Recommendations as Applied



# Start-Up Company Replisaurus in Kista (Sweden)

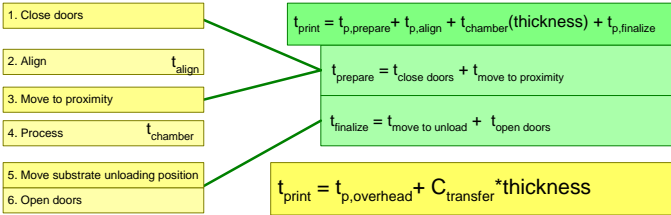
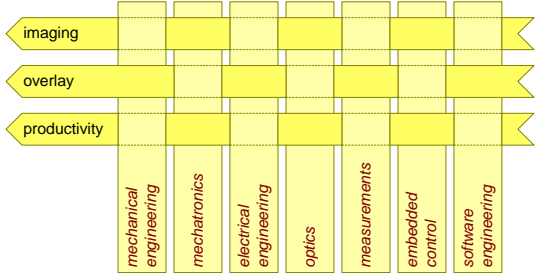


1. SE research

2. Start-up at Kista

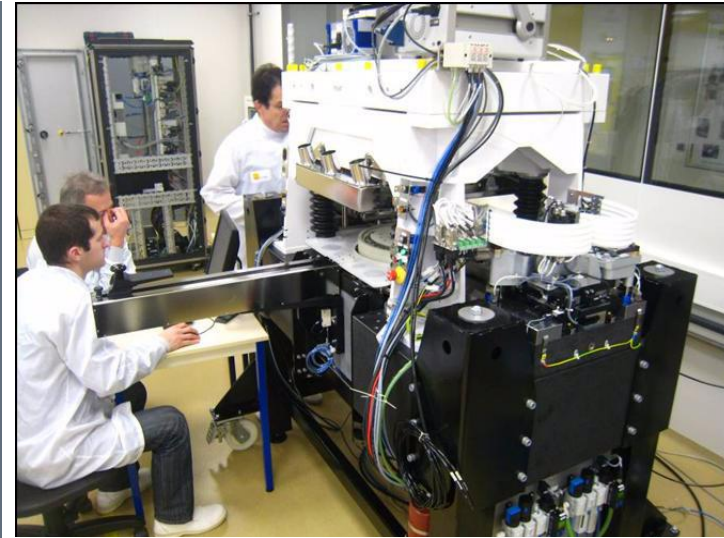
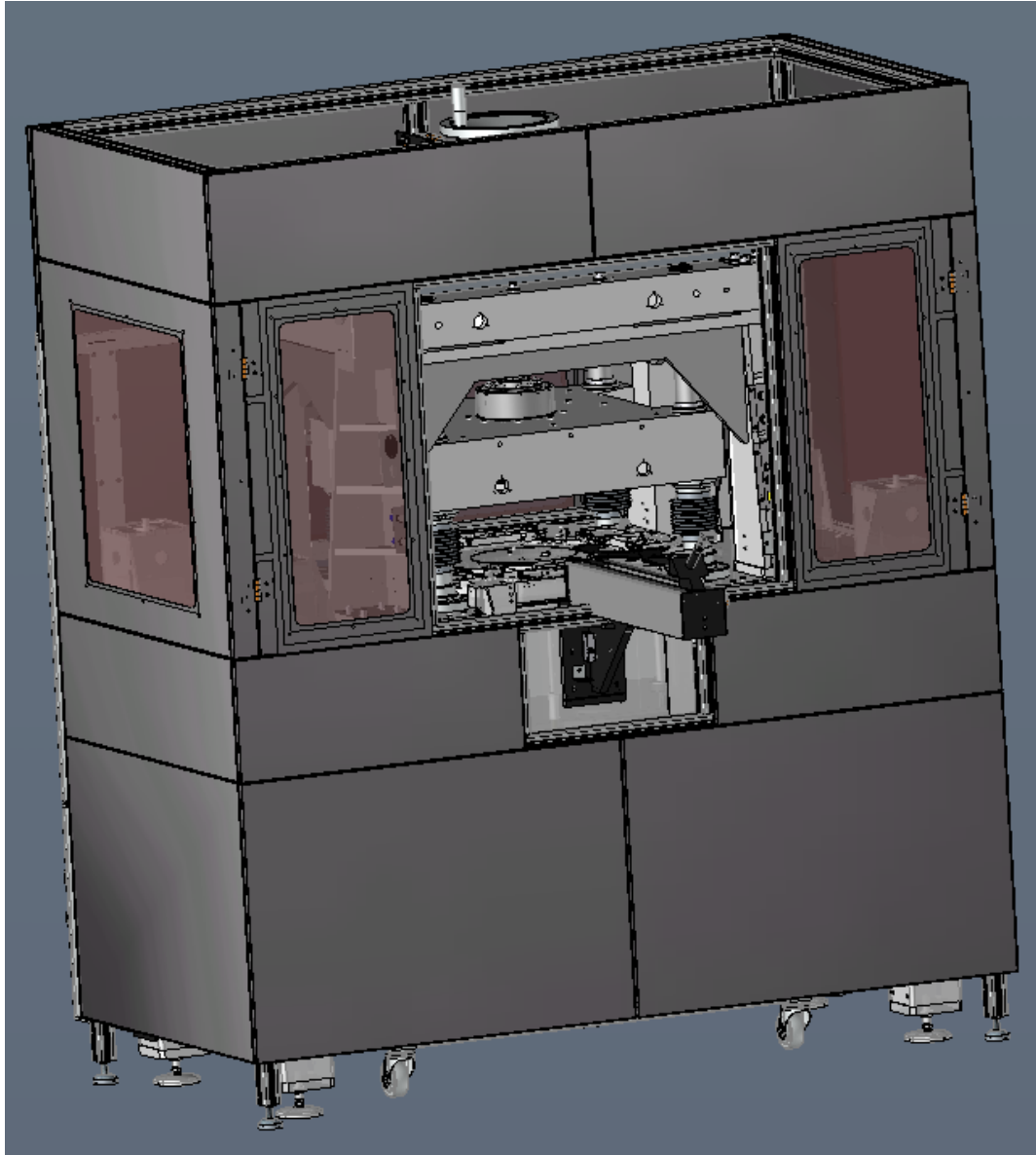
4. Evaluation

3. System Modeling

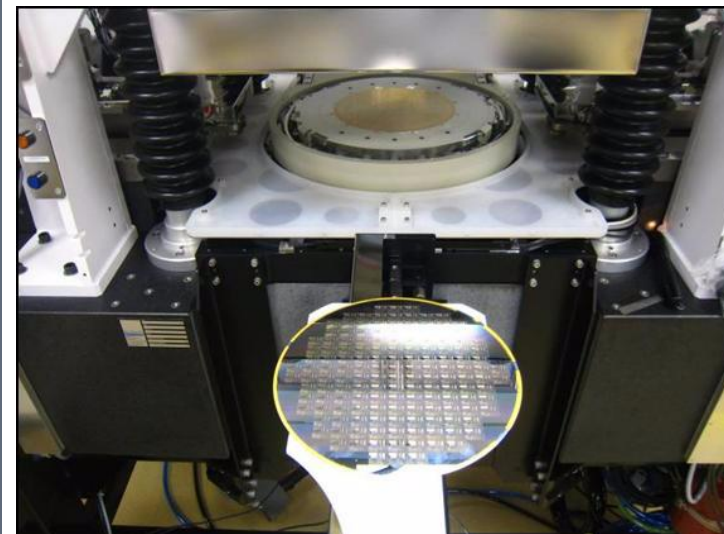


note: original diagram was annotated with actual performance figures for confidentiality reasons these numbers have been removed

# The Copper Printer



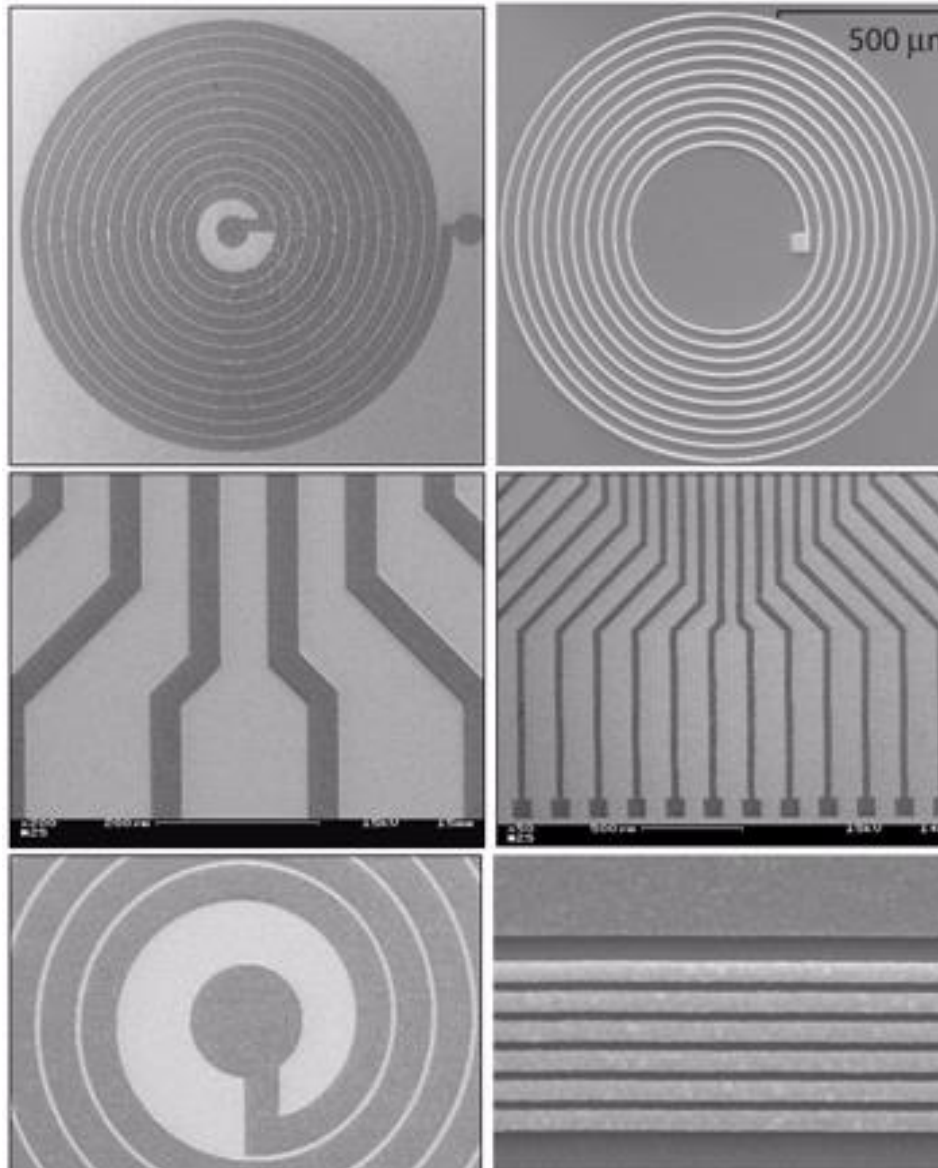
courtesy Replisaurus  
[www.replisaurus.com](http://www.replisaurus.com)





# Example of printed copper structures

---



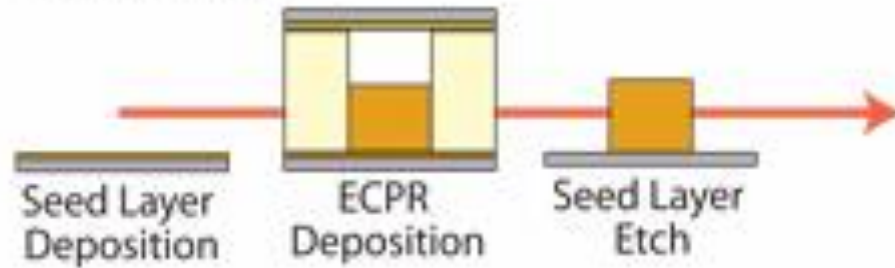
courtesy Replisaurus  
[www.replisaurus.com](http://www.replisaurus.com)



# ECPR technology replaces 6 process steps by 1 step

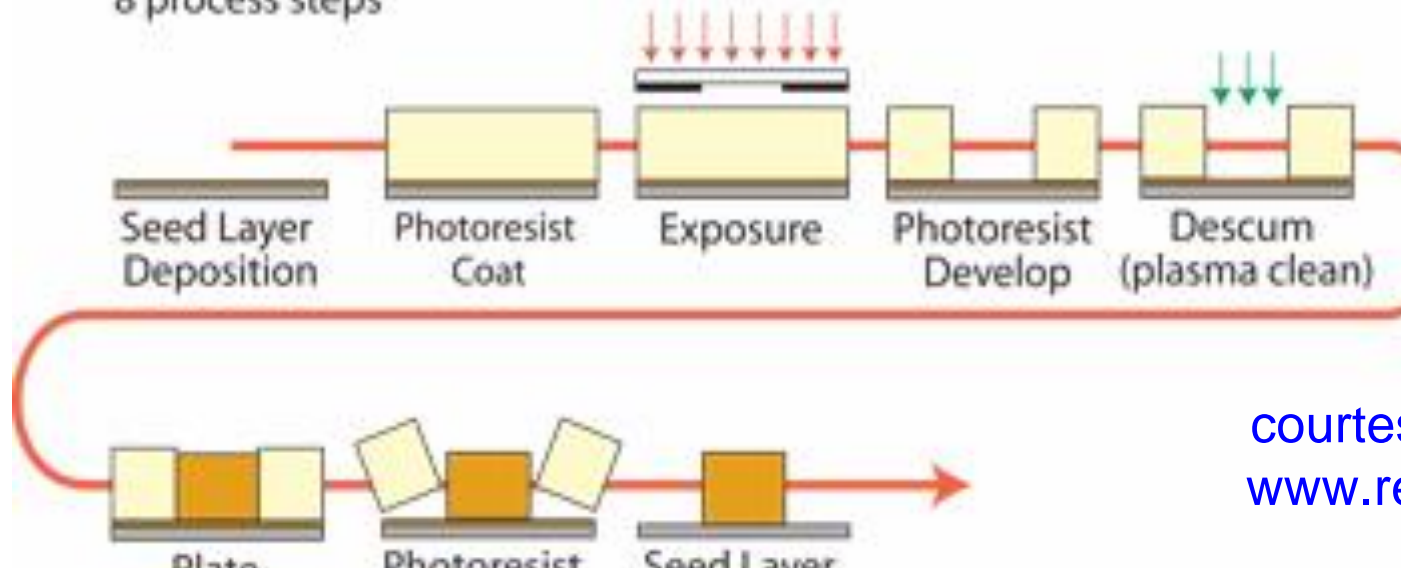
## ECPR - ElectroChemical Pattern Replication

3 process steps



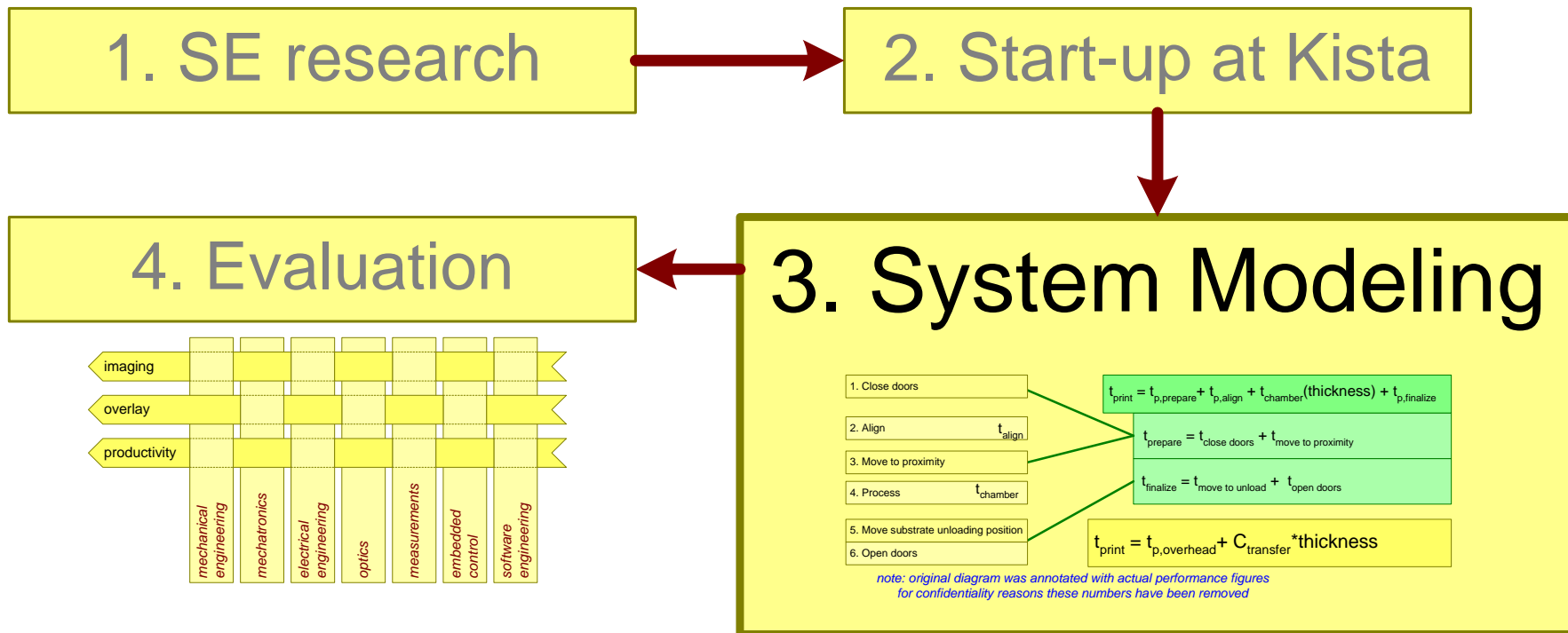
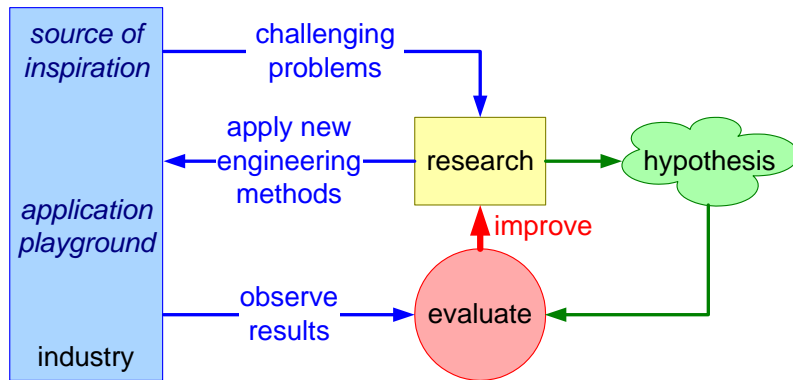
## Conventional lithography based metallization

8 process steps

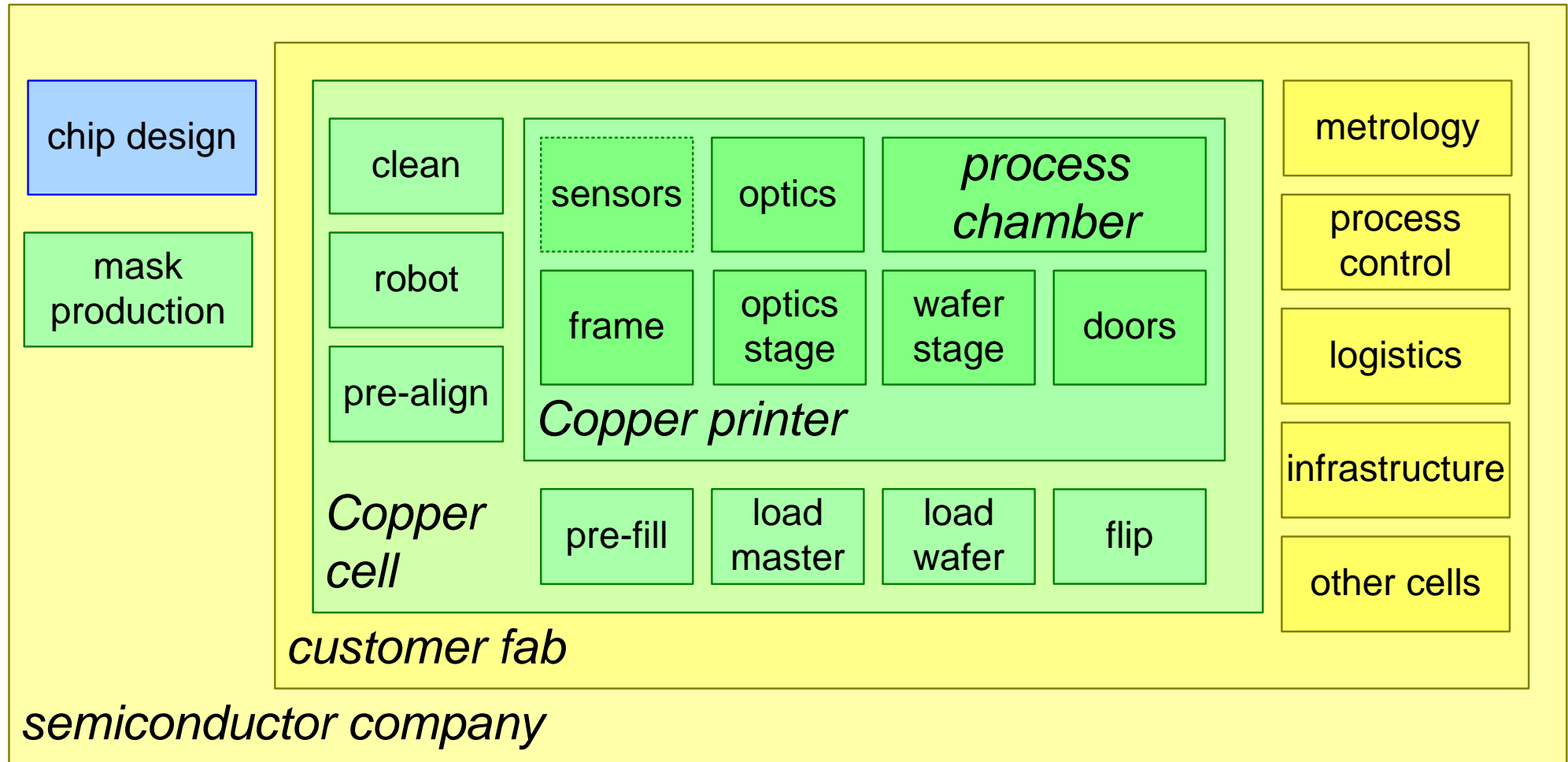


courtesy Replisaurus  
[www.replisaurus.com](http://www.replisaurus.com)

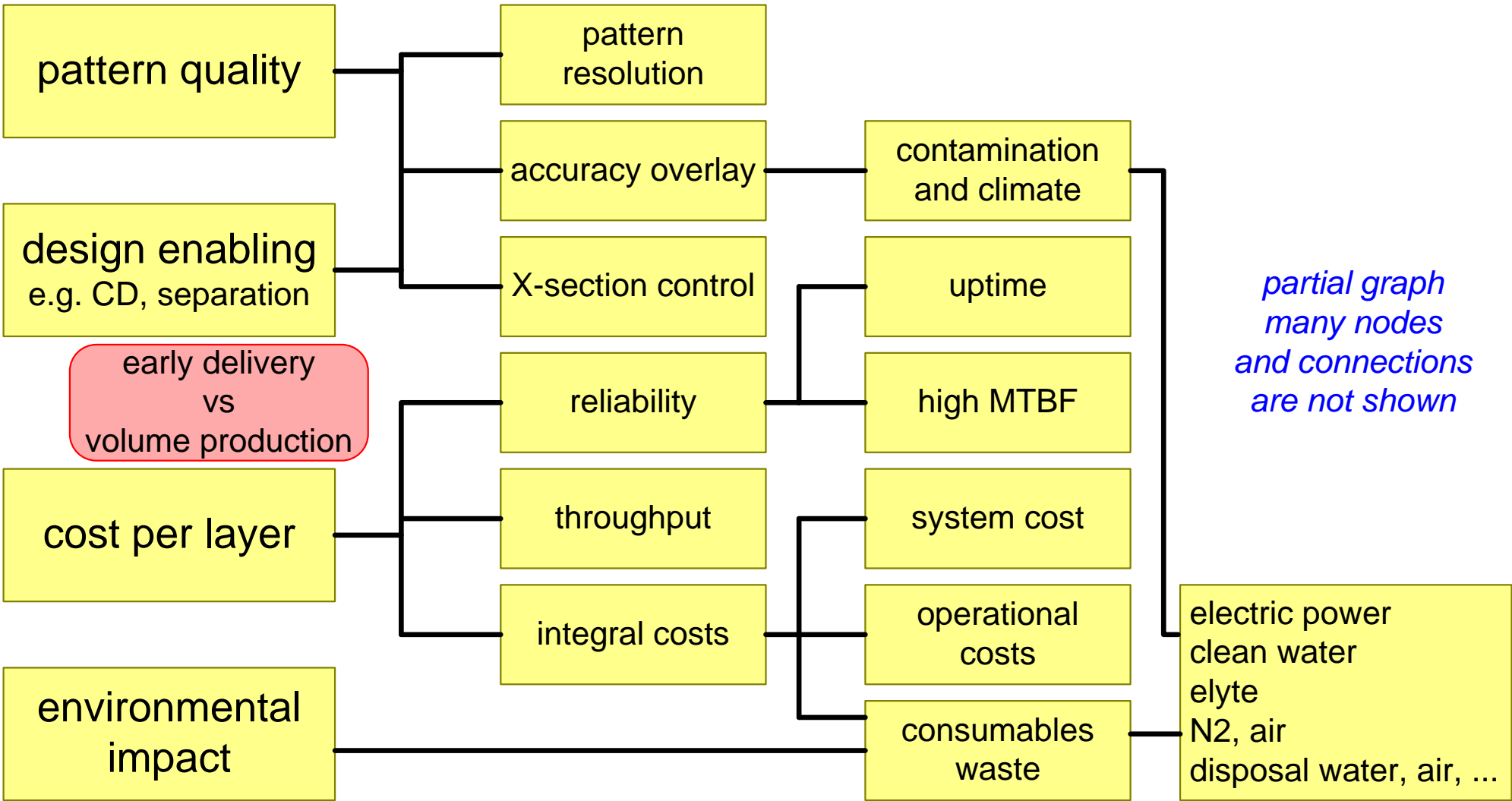
# System Modeling




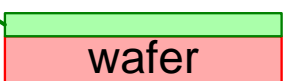
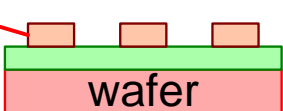
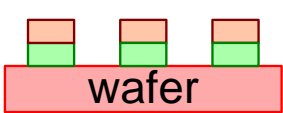
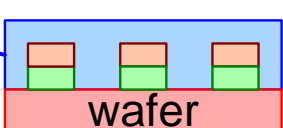
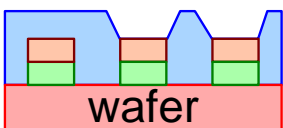

# Overview of the different scopes



# Customer key driver graph



# Process flow at fab level, from inspection until testing

		throughput in minutes	wafer	FOUP	
		1. inspection			
seed		2. seed sputter	1	25	
Cu		3. Cu print	2	50	target spec
		4. seed etch	1	20	
<p style="color: blue;">spin coated polymer</p> 		dual layer only			
		5. coat/develop dielectrics	3..4	50	75..100??
		6. exposure or CMP for polymer vias	1..2	30	
		7. E-test			

# Work flow in the Copper Printer

---

0. Loading Master&substrate

1. Close doors

2. Align

3. Move to proximity

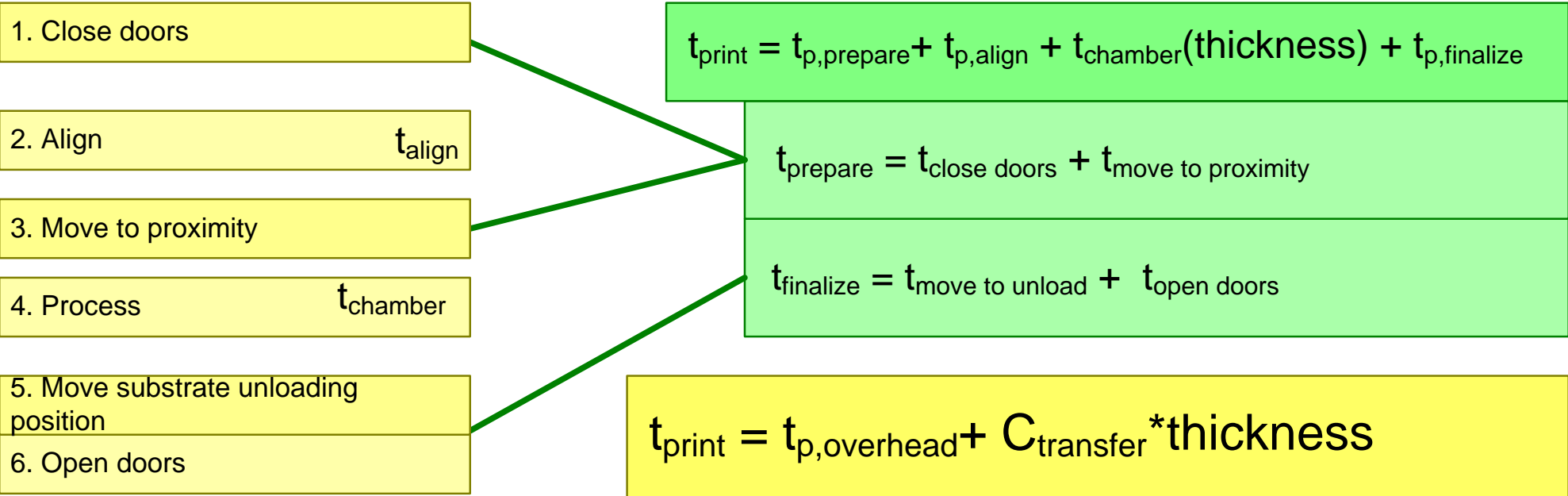
4. Process incl. rinse&dry

5. Move substrate unloading position

6. Open doors

7. Unloading Master&substrate

# Formula of printer throughput time



*note: original diagram was annotated with actual performance figures for confidentiality reasons these numbers have been removed*



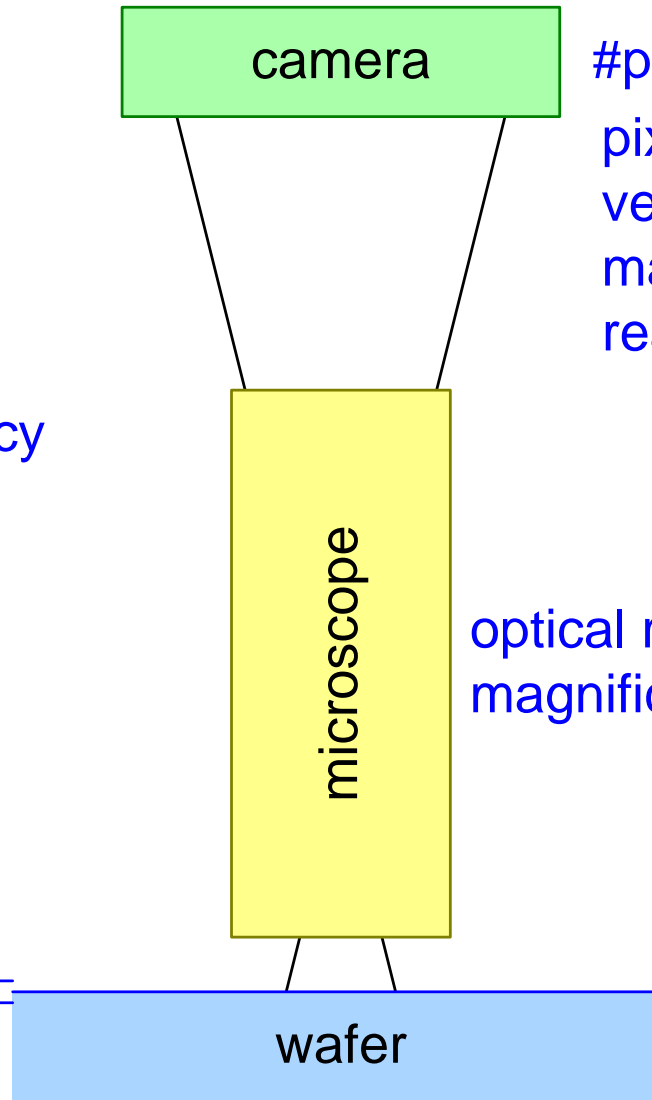
# Optical path to measure marker position



measurement accuracy  
determines  
required resolution



DoF

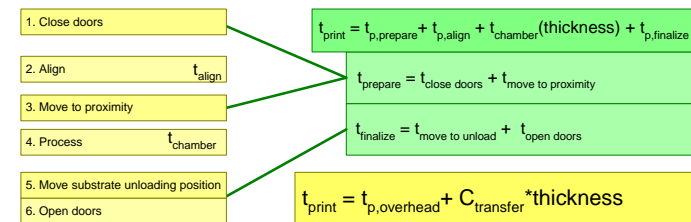
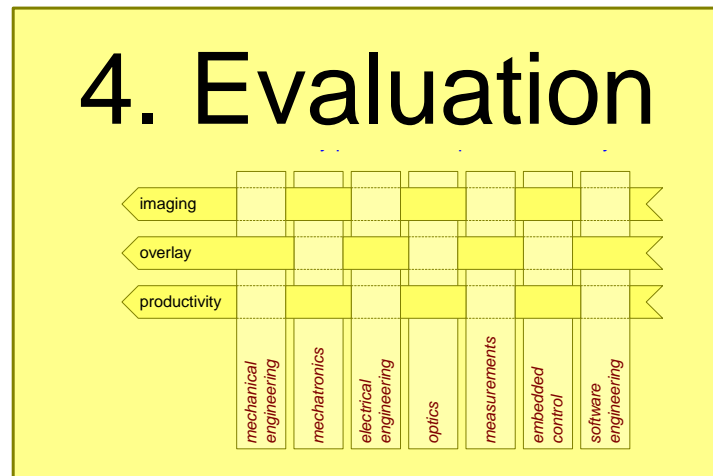
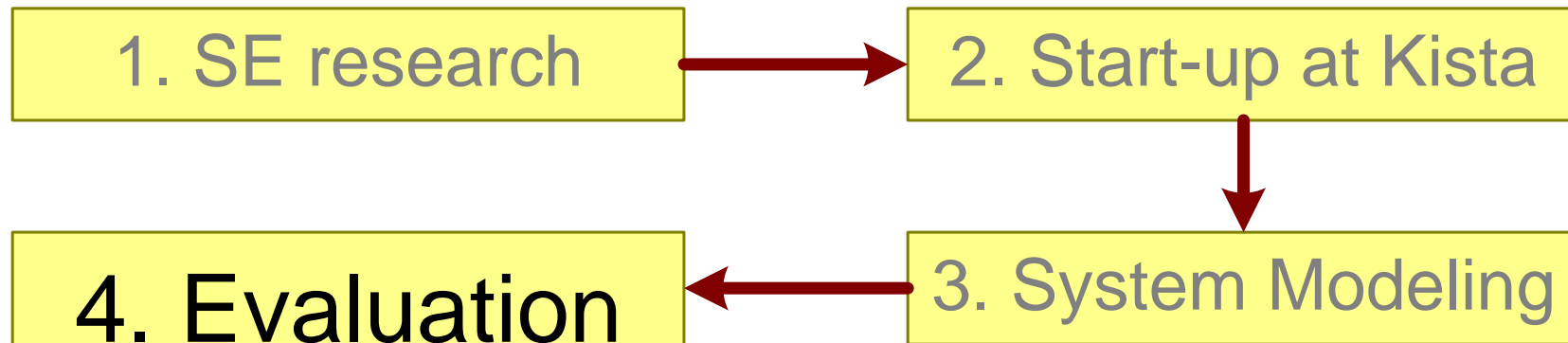
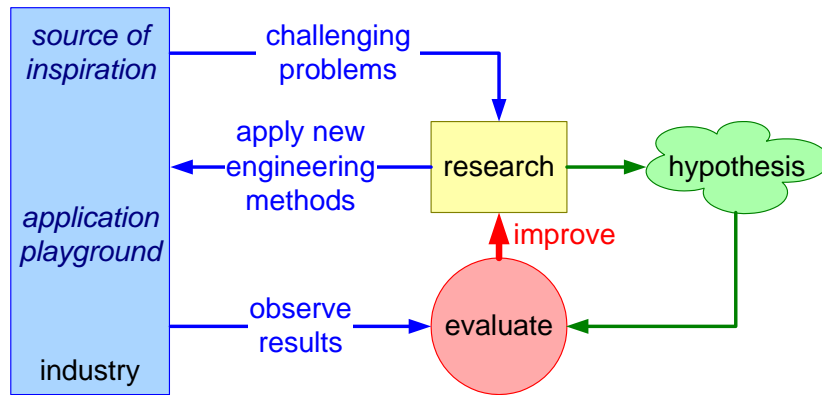


#pixels  $\approx$  5M  
pixel resolution  
versus  
maximum Field of View  
read-out and processing time

optical resolution  
magnification

displacement  
determines  
required Field of View

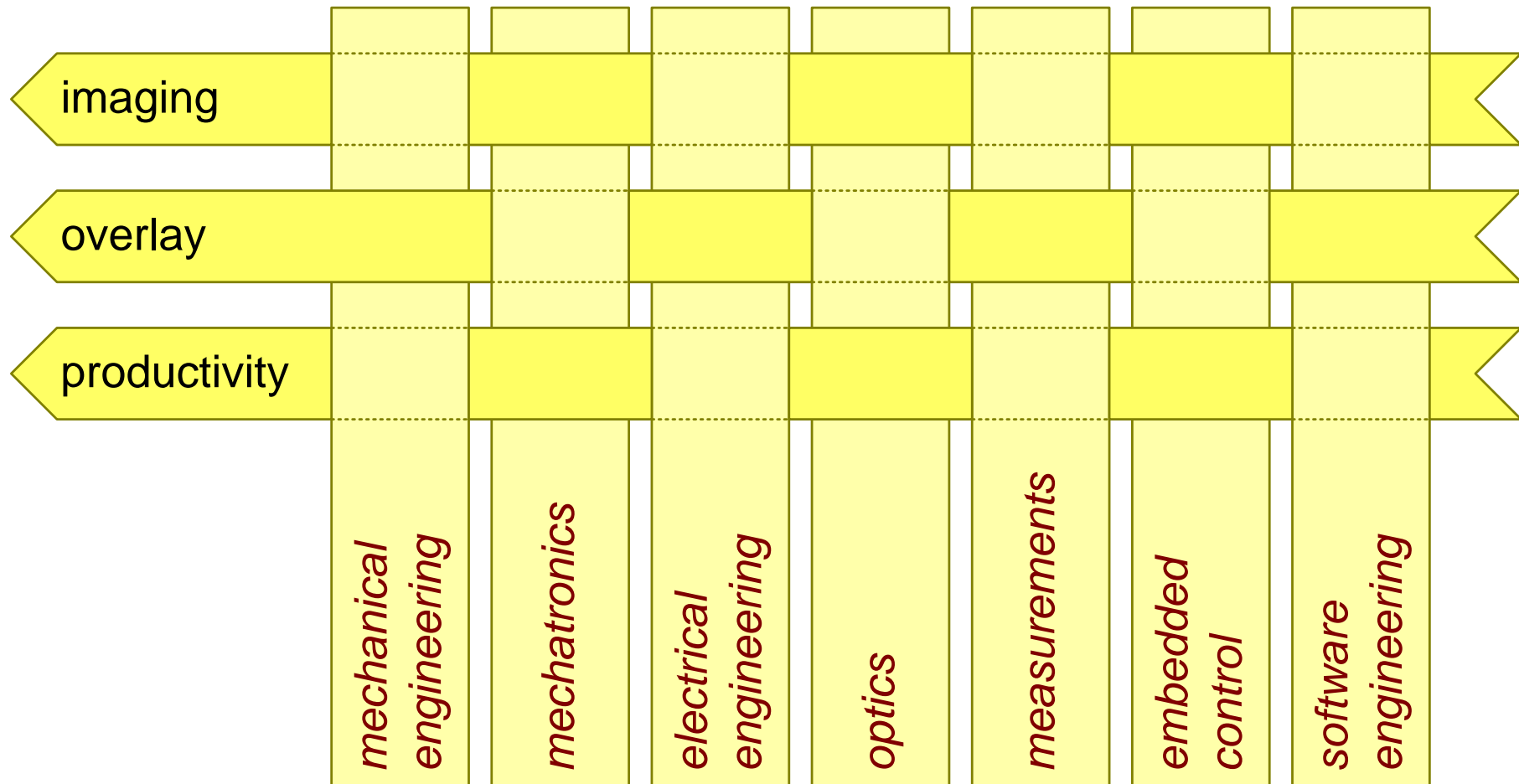
# Evaluation



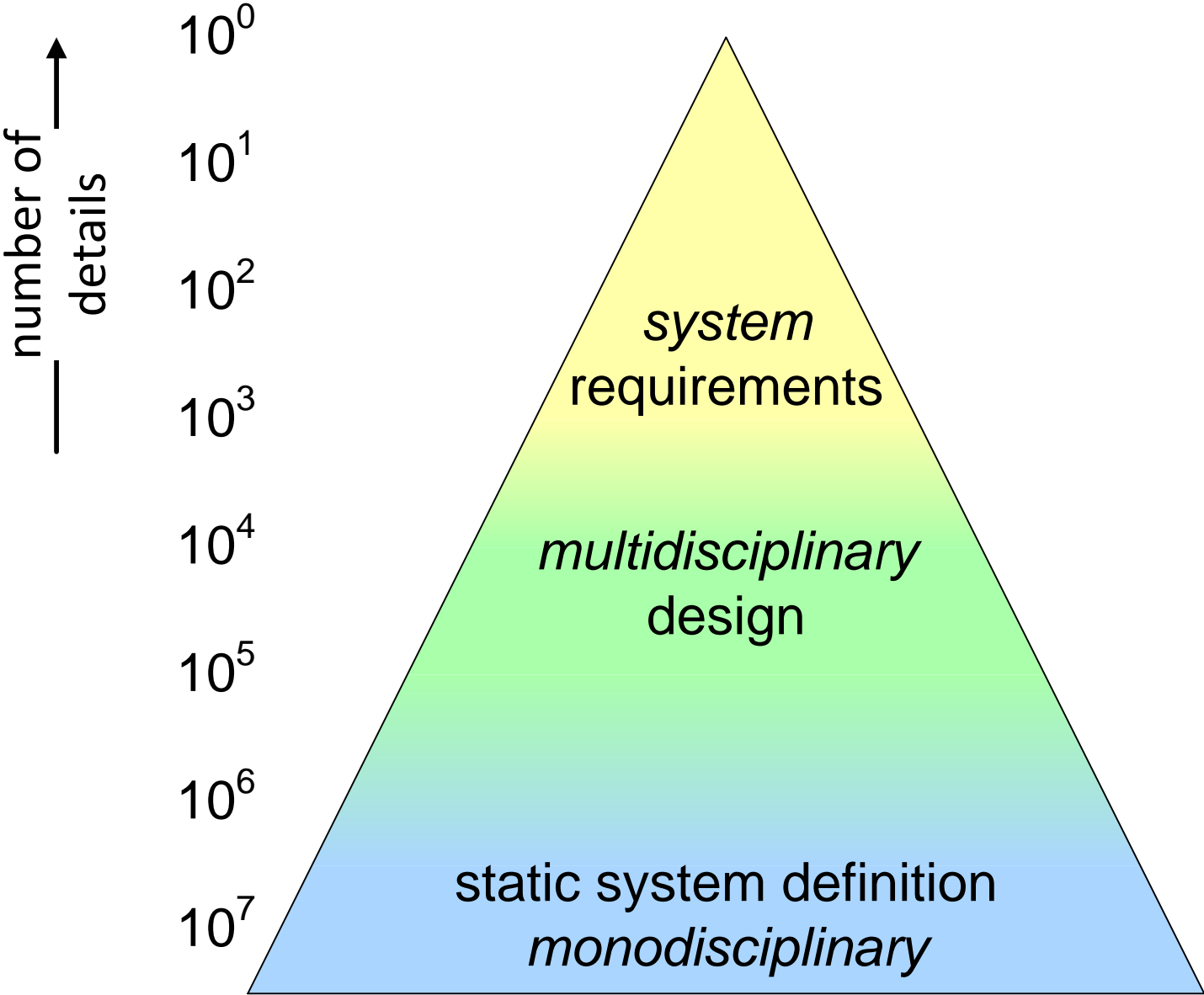
*note: original diagram was annotated with actual performance figures for confidentiality reasons these numbers have been removed*

# From Engineering Disciplines to System Qualities

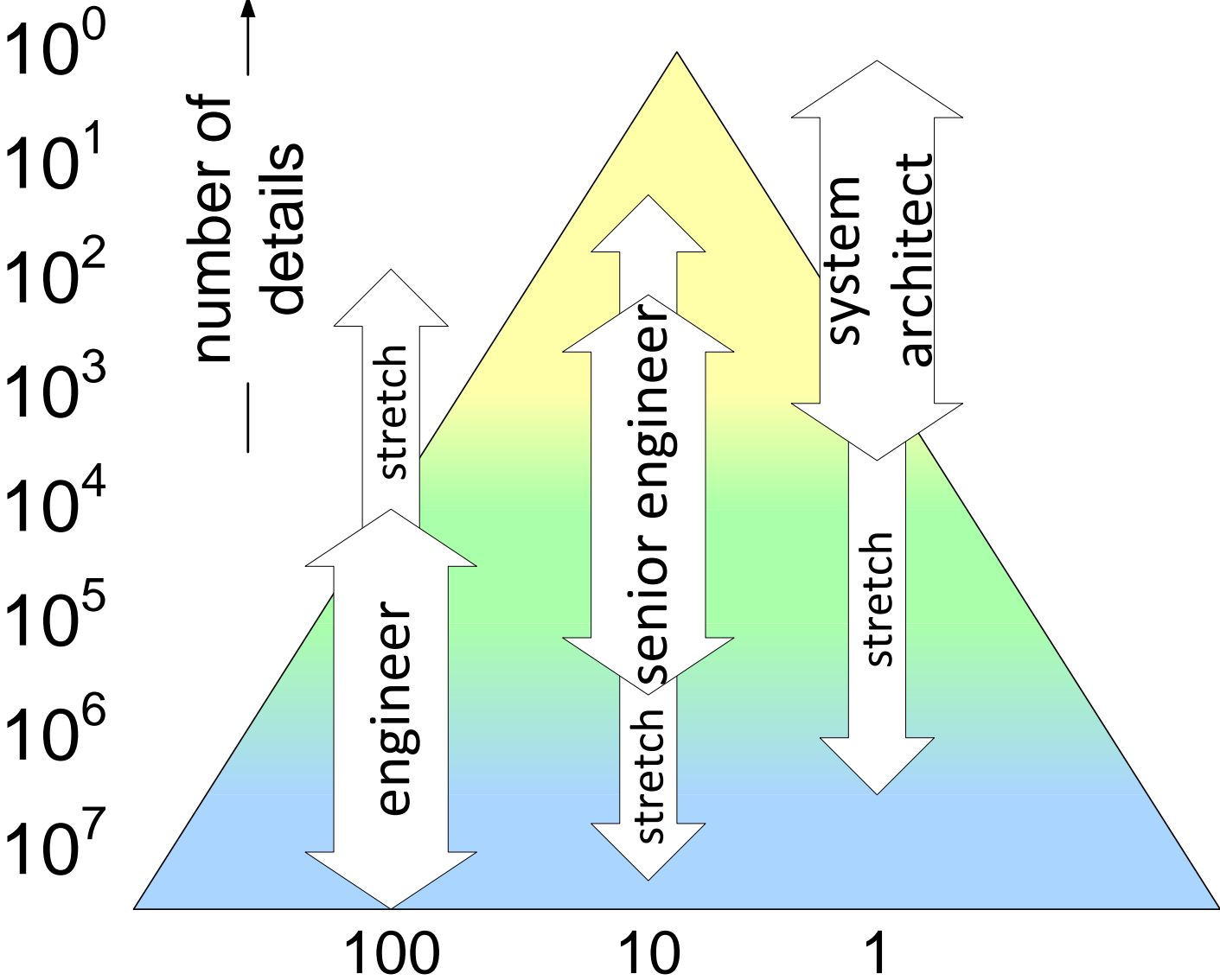
Systems Engineering: responsible for customer key drivers and key performance parameters of system



# Levels of Abstraction



# Lifting Engineers to System Concerns



Systems Engineering at Start-Up companies is applicable

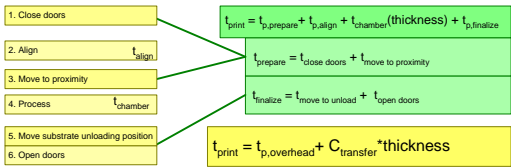
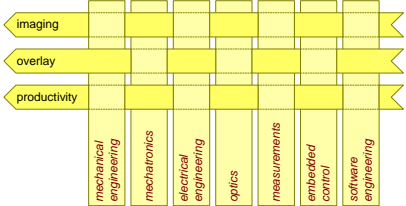
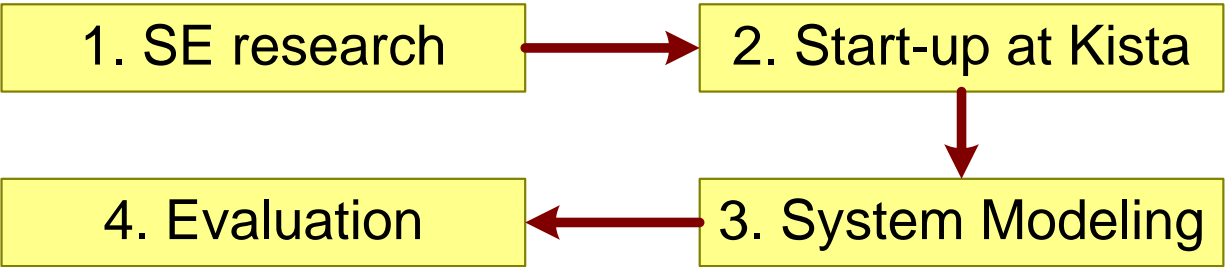
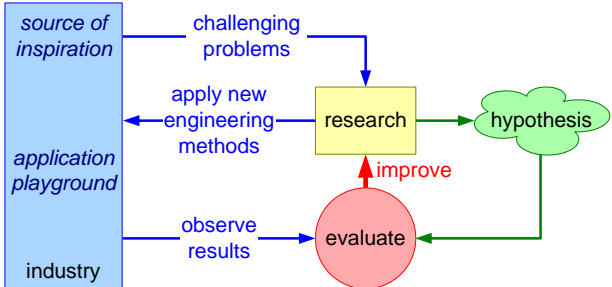
customization is required to adapt to:

company size

market and technology maturity

system models help to "lift" engineers to system level concerns

## Application of theory in practice



note: original diagram was annotated with actual performance figures for confidentiality reasons these numbers have been removed

is required for **learning and validation**